

<p>Form PTO-1449 O I P E INFORMATION DISCLOSURE CITATION IN AN APPLICATION MAR 03 2006 (Use several sheets if necessary)</p>				Document Number (Specified)	Application Number		
				HTIRC-02-015	10/734,422		
				Applicant	Jeiwei Chang et al.		
				Filing Date	12/12/03		
U. S. PATENT DOCUMENTS							
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE & APPROXIMATE	
DCD	6496334	12/17/02	Pang et al.	360	319	5/26/00	
DCD	6294101	9/25/01	Silverbrook	216	27	7/10/98	
DCD	5627704	5/6/97	Lederman et al.	360	113	2/12/96	
DCD	5668688	9/16/97	Dykes et al.	360	113	5/24/96	
FOREIGN PATENT DOCUMENTS							
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translitter	
						YES	NO
OTHER DOCUMENTS (Including Author, Title, Date, Page numbers, Etc.)							
DCD -	Co-pending U.S. Patent HTIRC-02-014, "Method of Adjusting CoFe Free Layer Magnetostriction" to M. Li et al., Serial No. 10/718,373, filed 11/20/03.						
EXAMINER				DATE CONSIDERED			
/Daborah Chacko-Davis/				05/11/2006			

**EXAMINER:** Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.